

Features:

- Centralized provision is suitable for points of use in multiple laboratories
- Suitable as washing system for semiconductors, components, and materials in manufacturing.
- Suitable for small-scale supply of pure water.
- Best quality with low cost
- All-time rapid and reliable A/S service



[Puris-RO5000P] [Puris-RO200P]

Specifications

Model	Product Rate L/Hr(M3/D)	Dimensions (W x D x H mm)	Inlet Dia. (Inch)	RO Memberanes (Øx L mm x EA)	Power(KW) 220/380V, 50/60Hz
Puris-RO100P	100(2.4)	700×600×1640	1/4	100×1016×1	1.0
Puris-RO200P	200(4.8)	700×600×1640	1/2	100×1016×1	1.0
Puris-RO500P	500(12)	700×600×1640	2/3	100×1016×2	1.5
Puris-RO750P	750(18)	700×600×1640	2/3	100×1016×2	2
Puris-RO1000P	1000(24)	2500×700×1500	3/3	100×1016×4	2.5
Puris-RO2000P	2000(48)	2500×700×1500	1.0	100×1016×8	3.0

- Customized production of the above models having different capacity is available.
- Production of pilot ultra-pure water is available as per optional system.

At any time, the manufacturer may bring modifications to the model above described, for technical or commercial reasons. The picture does not necessary shows the product in the standard version.